

This website uses cookies to improve the user's experience during working with our network and to provide users with dedicated services and functions. By further use you agree with that.OKDetails

Address	Echerkon Technologies Ltd. 20 Springfield Road, Crawley, RH11 8AD
---------	--

Country	United Kingdom
---------	----------------

PRODUCTS OR MACHINERY

Welcome to Echerkon Technologies Ltd. We provide equipment, processes and consultancy to the Photovoltaic industry.

Our Nitor 301 system is a flexible R&D deposition tool which uses Hot Filament Chemical Vapour Deposition (HFCVD), also known as Hot Wire Chemical Vapour Deposition (HWCVD). The wide substrate temperature range of 350 °C to 700 °C enables deposition of amorphous, microcrystalline and crystalline silicon films on materials such as glass, ceramics or silicon.

We also have experience and contacts throughout the photovoltaic and semiconductor industries. We are specialists in the layout, planning and realisation of technological solutions for high vacuum systems and exhaust-stream treatment from CVD process facilities

Company Profile of **Echerkon Technologies Ltd.**

A service of glasssglobal.com, an affiliate of glasssglobal group.

The address material you printed out is copyright and belongs to the Company or to its third party Marketing Agency, and all rights are reserved. Any User who accesses such material may do so only for its own personal use, and the use of such material is at the sole risk of the User. Redistribution or other commercial exploitation of such address material is expressly prohibited. Where such address material is provided by a third party, each User agrees to observe and be bound by the specific terms of use applying to such news material. Glass Global does not represent or endorse the accuracy or reliability of any of the info contained in any address or external websites referred to in this printout.www.glasssglobal.com - The International Portal to the Glass Industry - OGIS GmbH